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(71) Applicant (for all designated States except US): STORK PRINTS B.V. [NL/NL]; 3, Raamstraat, NL-5831 AT Boxmeer (NL).

(72) Inventor; and

- (75) Inventor/Applicant (for US only): BLANKENBORG, Stephanus, Gerardus, Johannes [NL/NL]; Veemarkt 10, NL-6511 ZD Nijmegen (NL).
- (74) Agent: VOLMER, J., C.; Exter Polak & Charlouis B.V., P.O. Box 3241, NL-2280 GE Rijswijk (NL).

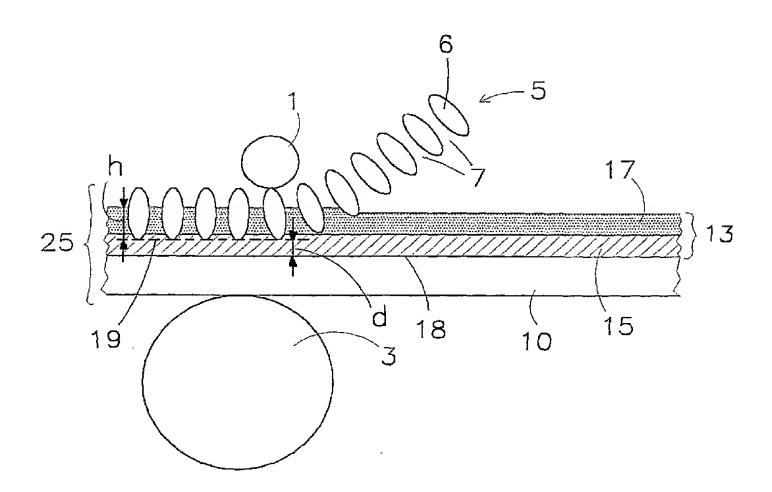
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(54) Title: METHOD FOR PRODUCING A BASE MATERIAL FOR SCREEN PRINTING, AND BASE MATERIAL OF THIS TYPE



(57) Abstract: Method for producing a base material (25) for screen printing, which comprises a protective film (10), a screen (5) and an intermediate resist layer (13) comprising photosensitive material, the method comprising the steps of applying a first resist layer (15) to one side of the protective film (10), drying the first resist layer (15), applying an additional resist layer (17) to the first resist layer (15), and then applying a screen (5) to the additional resist layer (17) under pressure, with that side of the additional resist layer (17) to which the screen (5) is applied being wet. The invention also describes a base material (25) for screen printing, which comprises a protective film (10), an electroformed screen (5) and an intermediate resist layer (13) comprising photosensitive material.



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